EEE118 Problem Class Questions – Sheet 4

Fundamental Constants

Boltzman Constant, $k = 1.381x10^{-23} \text{ JK}^{-1}$ Charge on Electron, $q = 1.602x10^{-19} \text{ C}$

- 1. A germanium p-n junction has a bulk resistivity of 4.2×10^{-4} and 2.08×10^{-2} Ωm for the p-and n-type material respectively. For germanium $\mu_e=0.3$, $\mu_h=0.15$ m²V⁻¹s⁻¹, and $n_i=2.5\times10^{19}$ m⁻³ at room temperature. Stating all assumptions;
 - a) Show the free electron carrier density in the n-type material is 1×10^{21} m⁻³.
 - b) Show that the free hole carrier density in the p-type material is 9.9×10^{22} m⁻³
 - c) Sketch the extent of the depletion region into the p-type and n-type material.
 - d) Calculate the hole (minority) carrier density in the n-type material.
 - e) Show the height of the potential barrier at the junction is 0.3V.
 - f) Can you estimate the band-gap of Ge?
 - g) Calculate the diffusion coefficients for the electrons and holes.
 - h) Is the saturation current mainly due to electrons or holes? (Assume the minority carrier lifetimes are identical).

EEE118 Solutions Sheet 4

1.

a) From notes, assuming minority carrier contribution is negligible

Rearranging and substituting
$$n = (\rho_e q \mu_e)^{-1} = (2.08 \times 10^{-2}.1.6 \times 10^{-19}.~0.3)^{-1}$$
 So n=1.0(0)x10²¹ m⁻³

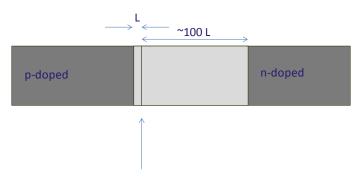
b) From notes, assuming minority carrier contribution is negligible $\rho_h = (pq\mu_h)^{-1}$

Rearranging and substituting
$$p = (\rho_h q \mu_h)^{-1} = (4.2 \times 10^{-4}.1.6 \times 10^{-19}. \ 0.15)^{-1}$$

So p=9.9(2)x10²² m⁻³

If we assume that all donors and acceptors are ionized, we can say that the donor density is 1.0×10^{21} m⁻³ and the acceptor density is 9.9×10^{22} m⁻³.

The ratio of space charge (ionized acceptors to donors) in a given length is in the ratio ~1:100. The depletion region is therefore 100 times thicker in the n-type compared to the p-type.



Physical or metallurgical interface

d) As
$$n_i^2 = n_n p_n$$

Plugging values in

$$\left(2.5x10^{19}\right)^2 = 1x10^{21} \cdot p_n$$

So
$$p_n = 6.25 \times 10^{17} \text{m}^{-3}$$

e) In order to calculate the potential height we use the relation:

$$V_0 = \frac{k_B T}{q} \ln \left(\frac{p_{(p)}}{p_n} \right)$$

Plugging in these values should give $V_0 = 0.3 \text{ V}$.

- f) We know that V_0 is usually quite close to the band-gap. So we can guess at a band-gap of $0.3 \sim 0.5$ eV
- g) To remind you, the Einstein relation relates diffusion coefficient to mobility and the thermal energy by

$$D_{e,h} = \frac{kT}{q} \mu_{e,h}$$

All that is required is to plug in the values - be careful to make sure kT is in Joules so choose your Boltzmann constant carefully (or remember to use the charge on the electron if you use eV.....)...

$$D_e = \frac{kT}{q}\mu_e = \frac{1.38x10^{-23}x300}{1.6x10^{-19}}x0.3 = 0.0078$$

For electrons $D_e = 0.0078 \text{ m}^2 \text{s}^{-1}$

$$D_h = \frac{kT}{q} \mu_h = \frac{1.38 \times 10^{-23} \times 300}{1.6 \times 10^{-19}} \times 0.15 = 0.0039$$

For electrons $D_e = 0.0039 \text{ m}^2 \text{s}^{-1}$

h)
$$I_0 = I_e + I_h = qAn_i^2 \left[\frac{D_e}{L_e N_A} + \frac{D_h}{L_h N_d} \right]$$

The saturation current is determined essentially by the ratio of doping concentrations (D differ by ~2, minority carrier lifetime identical). However – the electron diffusion current is inversely proportional to the *acceptor* doping density (and vice versa for holes)

For this asymmetrically doped junction, the diffusion current is mainly due to holes.